

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

Claims 1 - 6 (canceled).

Claim 7 (previously presented): A method of making a supported mask that may be used in modifying a substrate, comprising:

- obtaining a support that is not the substrate;
- applying at least one layer of dielectric material to said support; and
- exposing said layer to patterned light to substantially cause removal of said layer from said support in exposed areas,

wherein the exposing causes ablating of the exposed areas of the layer.

Claim 8 (currently amended): The method as in claim 7 wherein the patterned light is UV light from a laser.

Claims 9-14 (canceled).